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APPLICATION NUMBER	FILING or 371(c) DATE	GRP ART UNIT	FIL FEE REC'D	ATTY.DOCKET.NO	TOT CLAIMS	IND CLAIMS
10/539,569	08/18/2005	2812	2080	124305	21	8

CONFIRMATION NO. 4496

25944
OLIFF & BERRIDGE, PLC
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ALEXANDRIA, VA22320

CORRECTED FILING RECEIPT

Date Mailed: 10/02/2007

Receipt is acknowledged of this non-provisional patent application. The application will be taken up for examination in due course. Applicant will be notified as to the results of the examination. Any correspondence concerning the application must include the following identification information: the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. **If an error is noted on this Filing Receipt, please write to the Office of Initial Patent Examination's Filing Receipt Corrections. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections**

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Power of Attorney: The patent practitioners associated with Customer Number 25944

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP03/16887 12/26/2003

Foreign Applications

JAPAN 2002-379963 12/27/2002

If Required, Foreign Filing License Granted: 05/16/2006

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is **US10/539,569**

Projected Publication Date: Not Applicable

Non-Publication Request: No

Early Publication Request: No

Title

Plasma generator, ozone generator, substrate processing apparatus and manufacturing method of semiconductor device

Preliminary Class

438

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